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REMOVAL OF DILUTE BINARY AND TERTIARY GAS MIXTURE OF ACETALDEHYDE, AMMONIA AND
TRIMETHYL AMINE IN NITROGEN USING ELECTRON-ATTACHMENT REACTOR AT HIGH
TEMPERATURE



Mr. Apiluck Iad-uea

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By	Mr. Apiluck Iad-uea
Field of study	Chemical Engineering
Thesis Advisor	Professor Wiwut Tanthapanichakoon, Ph.D.
Thesis Co-advisor	Associate Professor Tawatchai Charinpanitkul, D.Eng.

Accepted by the Faculty of Engineering, Chulalongkorn University in Partial Fulfillment
of the Requirements for the Master's Degree

Dr. Lavansiri Dean of Faculty of Engineering
(Professor Direk Lavansiri, Ph.D.)

THESIS COMMITTEE

Vichitra Chongvisal Chairman
(Assistant Professor Vichitra Chongvisal, Ph.D.)

Wiwut Tanthanichakoon Thesis Advisor
(Professor Wiwut Tanthanichakoon, Ph.D.)

J. Charinpanitkul Thesis Co-advisor
(Associate Professor Tawatchai Charinpanitkul, D.Eng.)

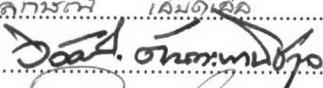
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(Associate Professor Wongapun Limpaseni, M.Sc.)

Prasert Pavasant Member
(Assistant Professor Prasert Pavasant, Ph.D.)

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ຈຸດປະສົງຄໍ່ຫລັກຂອງຈານວິຈັນນີ້ເອີ້ນ ສຶກຂາພລຂອງອຸພນຫຼວມທີ່ມີຕ່ອງການກຳຈັດກ້າຫະເຫດລັດໄໄສດໍ ແອນໂມນເນີຍແລະ ໄຕຣເມທີລອເມືນອອກຈາກກະແສກ້າຫະໄຟໂຕຣເຈນໂດຍໃຊ້ເຄື່ອງປົງກິຮົນນີ້ແບບເດີນອີເລີກຕອນ ກ້າຫະເປົ້າໝາຍເຫດລັນນີ້ມີກິລິນໆເໝັ້ນແລະເປັນກ້າຫະທີ່ປ່ອຍຈາກເຕາເພາະພທີ່ອຸພນຫຼວມສູງ ເນື່ອຈາກ ກ້າຫະທີ່ປ່ອຍຈາກເຕາເພາະພຈະມີທັກການນີ້ໄດ້ອອກໄໃຊດໍ ອອກຊີເຈນແລະ ໄອນ້າພສມອູ່ ດັ່ງນັ້ນປັ້ງຈັບທີ່ທຳການສຶກຂາ ທົດລອງໄດ້ແກ່ ຮັບຍະດີຂອງການນີ້ໄດ້ອອກໄໃຊດໍ ອອກຊີເຈນແລະ ຄວາມເຂັ້ມຂັ້ນຂອງໄອນ້າໃນກະແສກ້າຫະໄຟໂຕຣເຈນ ເພື່ອໃຫ້ເຂົາໃຈພລກຮະບບ່ານທີ່ກັນແລະ ກັນຮວ່າງກ້າຫະເປົ້າໝາຍ ການທົດລອງຈະມີທັກການກຳຈັດກ້າຫະເປົ້າໝາຍແຕ່ລະ ຜົນດົດເດື່ອຍ່າ ກ້າຫະເປົ້າໝາຍ 2 ຜົນດົດພຣັອມກັນ ແລະ ທັ້ງ 3 ຜົນດົດພຣັອມກັນດ້ວຍ ພລກາຣທົດລອງຈີ່ໃຫ້ເຫັນວ່າການທີ່ມີ ການນີ້ໄດ້ອອກໄໃຊດໍພສມອູ່ໃນກ້າຫະໄຟໂຕຣເຈນຈະຫ່ວຍເພີ່ມປະສິທິກາພກາກກຳຈັດກ້າຫະເປົ້າໝາຍໃຫ້ສູງເຊື້ອ ອັ້ນໆ ການມີອອກຊີເຈນພສມອູ່ໃນກ້າຫະໄຟໂຕຣເຈນຈະຫ່ວຍເພີ່ມປະສິທິກາພກາກກຳຈັດກ້າຫະເປົ້າໝາຍໃຫ້ສູງເຊື້ອທີ່ການ ກຳຈັດແບບໂດດເດື່ອຍ່າແລະ ການກຳຈັດແບບ 2 ແລະ 3 ຜົນດົດພຣັອມກັນ ສ່ວນການມີໄອນ້າຈະຫ່ວຍເພີ່ມປະສິທິກາພໃນ ການກຳຈັດກ້າຫະເປົ້າໝາຍຈາກກ້າຫະໄຟໂຕຣເຈນທີ່ອຸພນຫຼວມຕໍ່າ ແຕ່ຈະລດລົງເລັກນອຍທີ່ອຸພນຫຼວມສູງ ໃນການນີ້ທີ່ມີ ການນີ້ໄດ້ອອກໄໃຊດໍໃນກ້າຫະພສມໃນໄຟໂຕຣເຈນ ອອກຊີເຈນແລະ ໄອນ້າ ຈະທຳໄໝປະສິທິກາພກາກກຳຈັດສູງກວ່າການນີ້ທີ່ ໄນມີການນີ້ໄດ້ອອກໄໃຊດໍ

ອັນ້ນໆການສຶກຂາພລກຮະບບ່ານທີ່ກັນແລະ ກັນໃນການກຳຈັດກ້າຫະເປົ້າໝາຍ 2 ແລະ 3 ຜົນດົດພຣັອມກັນພບວ່າ ຈຳນວນໂມເລກວິຊາທີ່ມີກຳຈັດກ້າຫະເປົ້າໝາຍ 2 ແລະ 3 ຜົນດົດພຣັອມກັນພບວ່າ ກັນທັ້ງ 3 ຜົນດົດ ຈະມາກກວ່າເມື່ອເຖິງກັນການນີ້ກຳຈັດກ້າຫະເປົ້າໝາຍ 2 ຜົນດົດພຣັອມກັນ ນອກຈາກນີ້ເພື່ອລົດການເກີດ ພລິຕກັນທີ່ໄໝຕ້ອງການ ການປະບຸກຕິໃຊ້ເຄື່ອງປົງກິຮົນສອງຕັດຕ່ອອນກຽມ ຈຶ່ງໃຊ້ເຈື່ອນໄວໃນການທຳກັນພບວ່າ ກັນ ແສດໄໃຫ້ເຫັນແນວໃນນີ້ທີ່ດີສໍາຮັບການເພີ່ມປະສິທິກາພໃນການກຳຈັດແລະ ການລົດການເກີດເຊື້ອຂອງພລິຕກັນທີ່ໄໝຕ້ອງການ ໂດຍພວກວ່າ ໂອໂຈນ ແລະ NO_x ອູ້ກຳຈັດໄດ້ທັງໝົດແຕ່ການນອນອກໄໃຊດໍຈະເພີ່ມນາກເຊື້ອມື່ອກະແສ ເພີ່ມນາກເຊື້ອມື່ອກະແສ

ກາກວິชา.....	ວິສວກຮົມເຄມີ.....	ລາຍມື້ອໍ້ອື່ນສິດ.....	ລວມຕັກນົກ.....
ສາຂາວິชา.....	ວິສວກຮົມເຄມີ.....	ລາຍມື້ອໍ້ອື່ອຈາກຍົກລົງທີ່ປະກາດ.....	
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4470643521 : MAJOR CHEMICAL ENGINEERING

KEY WORD: GASEOUS POLLUTANT / GAS PURIFICATION / ELECTRON ATTACHMENT / CORONA DICHARGE / HIGH TEMPERATURE

APILUCK IAD-UEA : THESIS TITLE. (REMOVAL OF DILUTE BINARY AND TERTIARY GAS MIXTURE OF ACETALDEHYDE, AMMONIA AND TRIMETHYL AMINE IN NITROGEN USING ELECTRON-ATTACHMENT REACTOR AT HIGH TEMPERATURE) THESIS ADVISOR: PROF. WIWUT TANTHAPANICHAKOON, Ph.D., THESIS CO-ADVISOR : ASSOC. PROF. TAWATCHAI CHARINPANITKUL, D.Eng, 296 pp. ISBN 974-17-4531-1.

The main objective of this research is to investigate the effect of temperature on the removal of acetaldehyde, ammonia and trimethyl amine gases from N_2 using electron attachment reactor. The target gases are malodorous gaseous components emitted at high temperature from a crematory furnace. Since the emitted gases from a crematory furnace consist of CO_2 , O_2 and water vapor, the factors investigated are percentage of coexisting CO_2 , O_2 and the concentration of water vapor in the N_2 gas stream. To understand the effect between the target gases, the experiments are carried out both for the separate removal of target gases and the simultaneous removal of 2 and 3 target gases. The experimental results reveal that, it is found that the presence of carbon dioxide does significantly affect the removal efficiency. The higher the CO_2 concentration is employed, the higher the removal efficiency become, the presence of oxygen enhances the removal efficiency of the target gases both in the separate removal of target gases and the simultaneous removal of 2 and 3 target gases. The presence of water vapor enhances the removal efficiency of the target gases from N_2 at low temperature but slightly retards it at high temperature. The presence of CO_2 in nitrogen, oxygen and water vapor mixture has adverse effect on the removal efficiency.

The effects between the target gases on the simultaneous removal of 2 and 3 target gases are investigated. It is found that in the case of the simultaneous removal of 3 target gases, the number of acetaldehyde, ammonia and trimethyl amine gas molecules captured by an electron are higher than in the case of simultaneous removal of these 2 target gases. Furthermore, the application of two independently operated corona-discharge reactors in series is shown to have a good and promise for enhancing the removal efficiency and minimizing the generation of byproducts. It is found that the effluent O_3 and NO_x are removed completely. On the other hand, CO increases, current increases.

Department.....Chemical Engineering..... Student's signature.....*Apiluck Iad-nea*.....

Field of study.....Chemical Engineering..... Advisor's signature.....*W. Tantapanichakoon*.....

Academic year.....2003.....Co-advisor's signature.....*J. Charinpanitkul*.....

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NOMENCLATURE

C_{in}	=	inlet concentration [ppm]
$C_{out,0\text{ mA}}$	=	outlet concentration [ppm] when using zero current
$C_{out,Any\text{ mA}}$	=	outlet concentration [ppm] when using non-zero current
$[]_{in}$	=	inlet concentration [ppm]
$[]_{out}$	=	outlet concentration [ppm]
A	=	cross sectional area [m^2]
D_l	=	anode diameter [m]
D_o	=	cathode diameter [m]
E	=	electric field strength [V m^{-1}]
I	=	discharge current [mA]
N	=	gas density [mol m^{-3}]
N_r	=	number of gas molecules removed per unit time [s^{-1}]
N_{e0}	=	number of emitted electrons per unit time [s^{-1}]
$q_{out, 0\text{ mA}}$	=	the molar flow rate at reactor outlet without current [mol s^{-1}]
$q_{out \text{ at any mA}}$	=	the molar flow rate of at reactor outlet with current [mol s^{-1}]
p	=	total pressure [atm]
P	=	power consumption [W]
R	=	radial distance from the cylindrical axis [m]
R	=	gas constant [$0.082057 \text{ dm}^3 \text{ atm K}^{-1} \text{ mol}^{-1}$]
T	=	temperature [$^\circ\text{C}$]
SV	=	space velocity [hr^{-1}]
V	=	discharge voltage [V]
V_r	=	effective volume of the corona discharge reactor [m^3]
θ	=	mean residence time [s]
$\langle v \rangle$	=	superficial velocity [m/s]
ψ	=	apparent removal efficiency [-]
ψ'	=	removal efficiency excluding adsorption effect [-]
ψ''	=	removal efficiency per unit residence time [-]
ψ_{elec}	=	electron-based efficiency [-]
ψ_{ener}	=	energy-based efficiency [mol gas J^{-1}]